To all our customers

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Renesas Technology Corp.
Customer Support Dept.
April 1, 2003

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BB502C

Build in Biasing Circuit MOS FET IC
UHF RF Amplifier

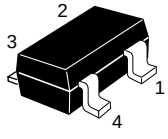
ADE-208-810C (Z)
4th. Edition
Mar. 2001

Features

- Build in Biasing Circuit; To reduce using parts cost & PC board space.
- Low noise; NF = 1.6 dB typ. at f = 900 MHz
- High gain; PG = 22 dB typ. at f = 900 MHz
- Withstanding to ESD;
  Build in ESD absorbing diode. Withstand up to 200V at C=200pF, Rs=0 conditions.
- Provide mini mold packages; CMPAK-4(SOT-343mod)

Outline

CMPAK-4



1. Source
2. Gate1
3. Gate2
4. Drain

Note: 1. Marking is “BS–”.
2. BB502C is individual type number of HITACHI BBFET.

Absolute Maximum Ratings (Ta = 25°C)

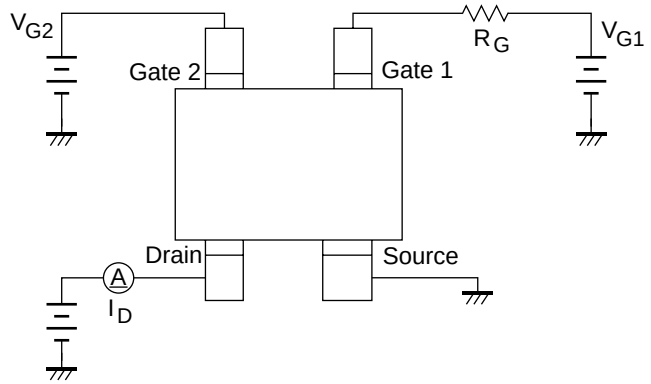
Item	Symbol	Ratings	Unit
Drain to source voltage	V_{DS}	6	V
Gate1 to source voltage	V_{G1S}	+6 –0	V
Gate2 to source voltage	V_{G2S}	+6 –0	V
Drain current	I_D	20	mA
Channel power dissipation	Pch	100	mW
Channel temperature	Tch	150	°C
Storage temperature	Tstg	–55 to +150	°C

Electrical Characteristics (Ta = 25°C)

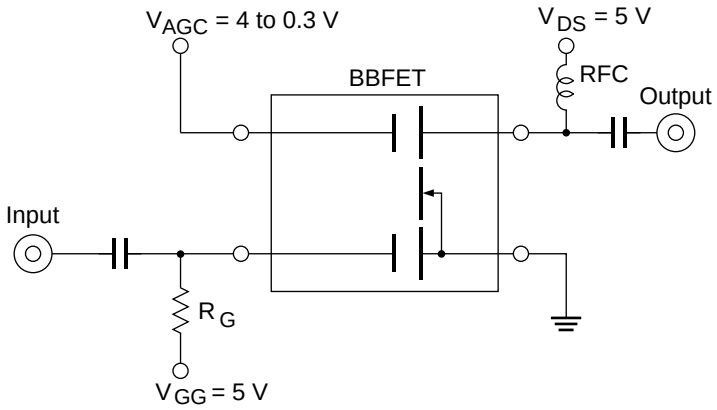
Item	Symbol	Min	Typ	Max	Unit	Test Conditions
Drain to source breakdown voltage	$V_{(BR)DSS}$	6	—	—	V	I_D = 200µA $V_{G1S} = V_{G2S}$ = 0
Gate1 to source breakdown voltage	$V_{(BR)G1SS}$	+6	—	—	V	I_{G1} = +10µA $V_{G2S} = V_{DS}$ = 0
Gate2 to source breakdown voltage	$V_{(BR)G2SS}$	+6	—	—	V	I_{G2} = +10µA $V_{G1S} = V_{DS}$ = 0
Gate1 to source cutoff current	I_{G1SS}	—	—	+100	nA	V_{G1S} = +5V $V_{G2S} = V_{DS}$ = 0
Gate2 to source cutoff current	I_{G2SS}	—	—	+100	nA	V_{G2S} = +5V $V_{G1S} = V_{DS}$ = 0
Gate1 to source cutoff voltage	$V_{G1S(off)}$	0.5	0.7	1.0	V	V_{DS} = 5V, V_{G2S} = 4V I_D = 100µA
Gate2 to source cutoff voltage	$V_{G2S(off)}$	0.5	0.7	1.0	V	V_{DS} = 5V, V_{G1S} = 5V I_D = 100µA
Drain current	$I_{D(op)}$	8	11	14	mA	V_{DS} = 5V, V_{G1} = 5V V_{G2S} = 4V, R_G = 180kΩ
Forward transfer admittance	$\|y_{fs}\|$	20	25	30	mS	V_{DS} = 5V, V_{G1} = 5V V_{G2S} =4V R_G = 180kΩ, f = 1kHz
Input capacitance	c_{iss}	1.4	1.7	2.0	pF	V_{DS} = 5V, V_{G1} = 5V
Output capacitance	c_{oss}	0.7	1.1	1.5	pF	V_{G2S} =4V, R_G = 180kΩ
Reverse transfer capacitance	c_{rss}	—	0.02	0.05	pF	f = 1MHz
Power gain	PG	17	22	—	dB	V_{DS} = 5V, V_{G1} = 5V V_{G2S} =4V, R_G = 180kΩ
Noise figure	NF	—	1.6	2.2	dB	f = 900MHz

Main Characteristics

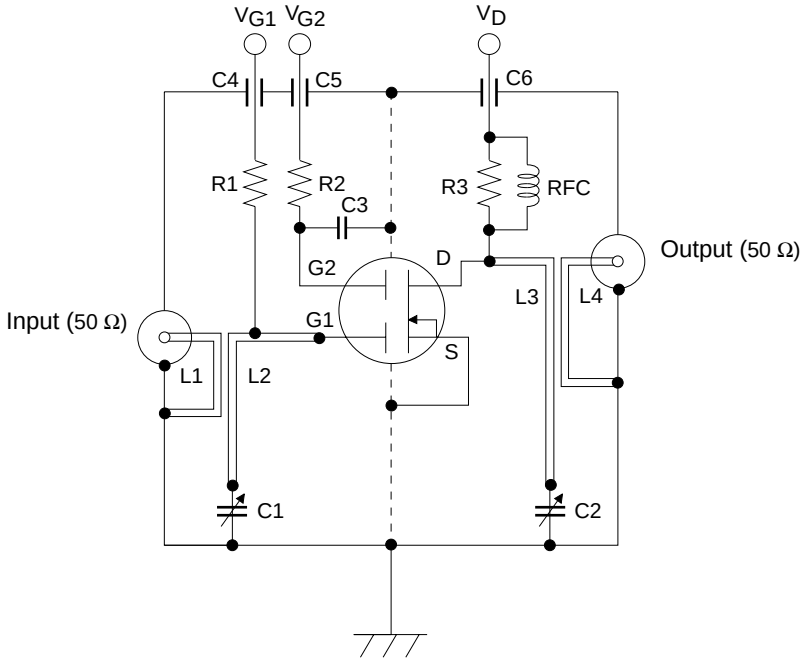
Test Circuit for Operating Items ($I_{D(op)}$, |yfs|, Ciss, Coss, Crss, NF, PG)



Application Circuit

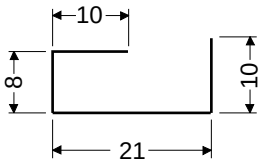


900MHz Power Gain, Noise Figure Test Circuit

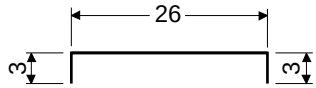


C1, C2: Variable Capacitor (10pF MAX)
C3: Disk Capacitor (1000pF)
C4 to C6: Air Capacitor (1000pF)
R1: 180 kΩ
R2: 47 kΩ
R3: 4.7 kΩ

L1:

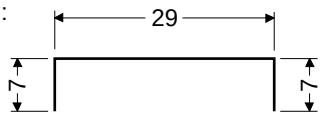


L2:

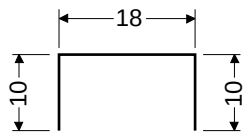


(ϕ1mm Copper wire)
Unit: mm

L3:

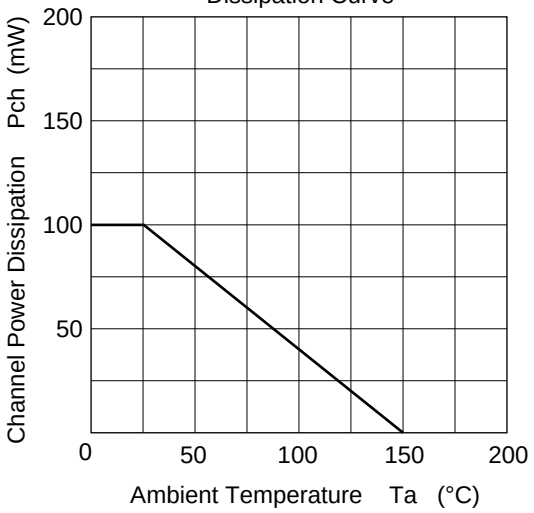


L4:

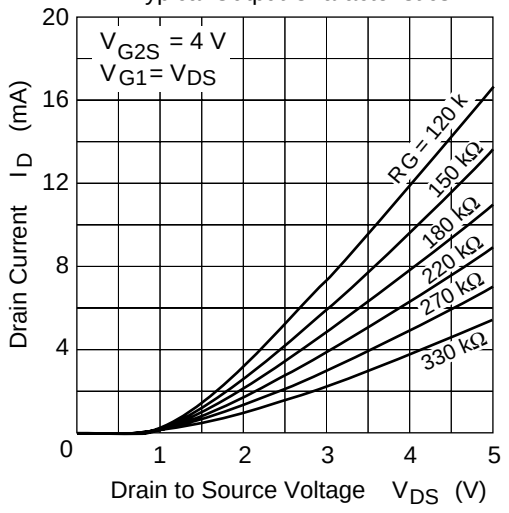


RFC: ϕ1mm Copper wire with enamel 4turns inside dia 6mm

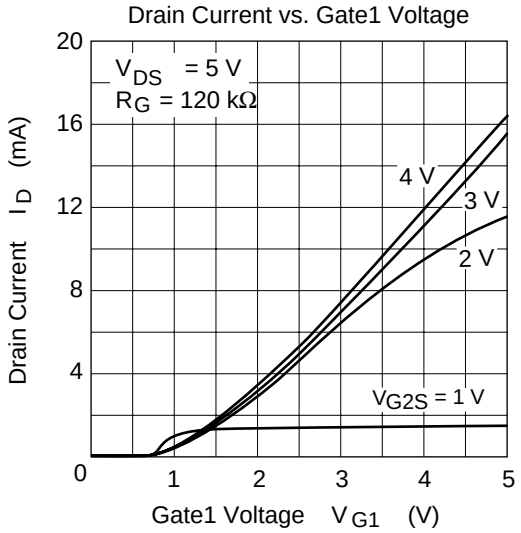
Maximum Channel Power Dissipation Curve



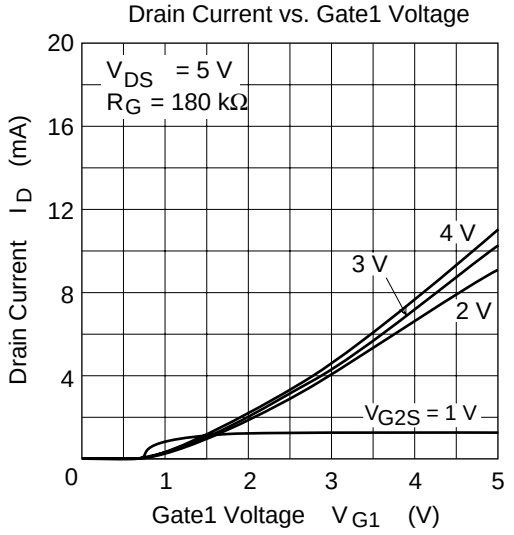
Typical Output Characteristics



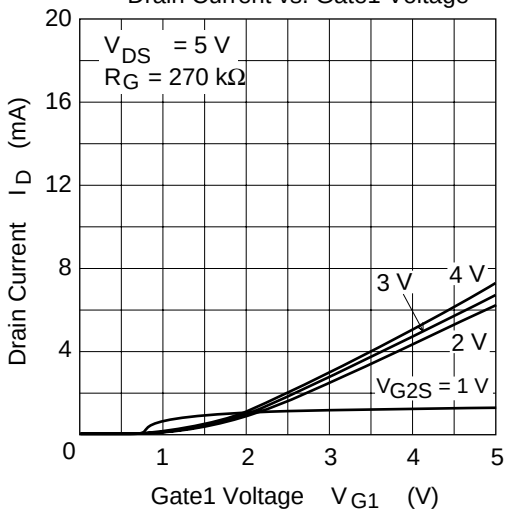
Drain Current vs. Gate1 Voltage



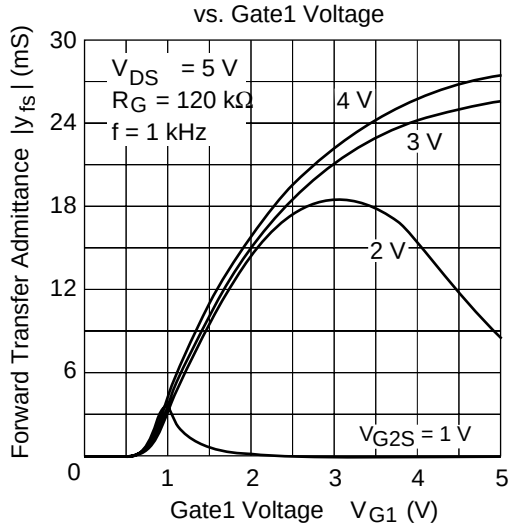
Drain Current vs. Gate1 Voltage



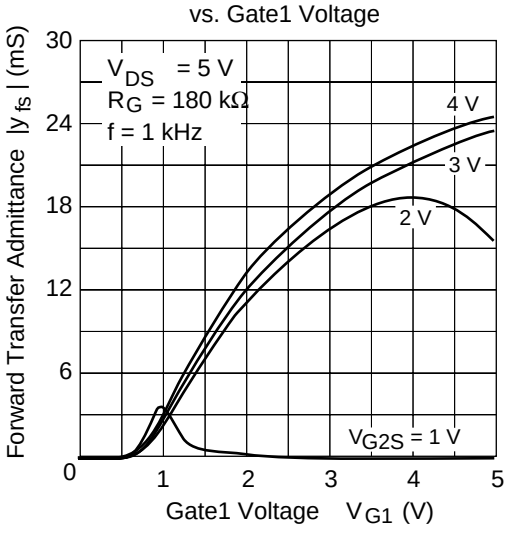
Drain Current vs. Gate1 Voltage



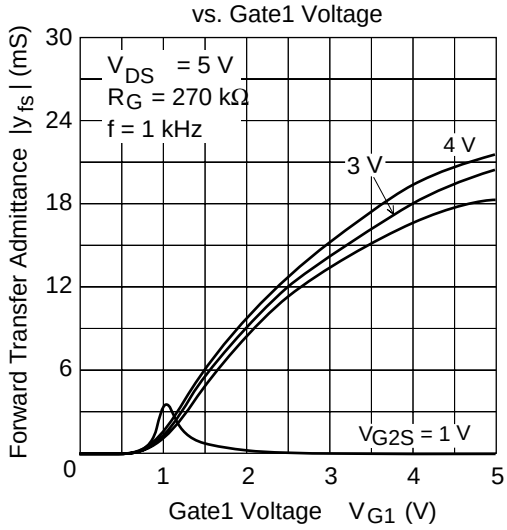
Forward Transfer Admittance vs. Gate1 Voltage



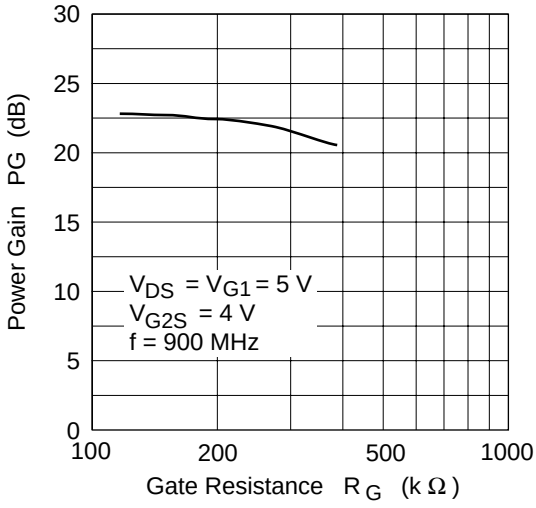
Forward Transfer Admittance vs. Gate1 Voltage



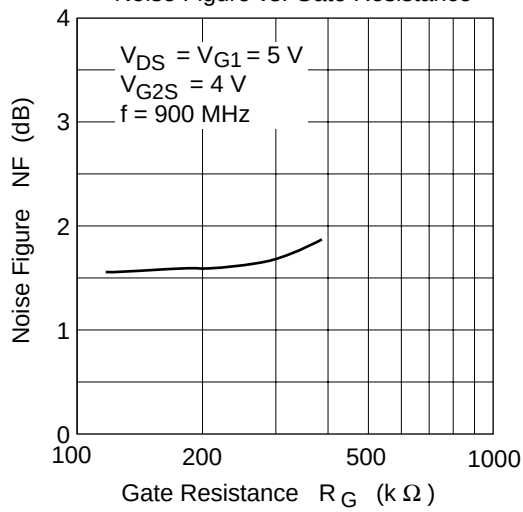
Forward Transfer Admittance vs. Gate1 Voltage



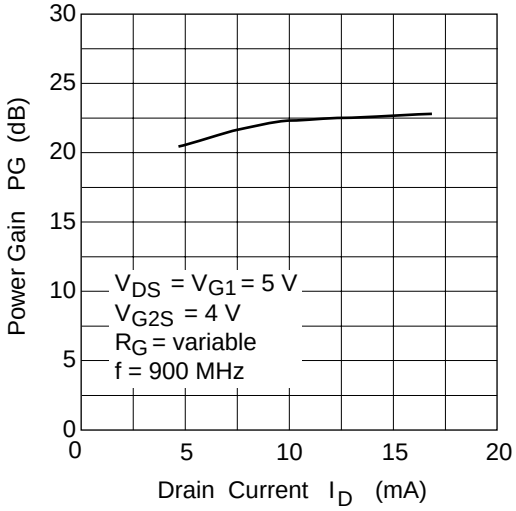
Power Gain vs. Gate Resistance



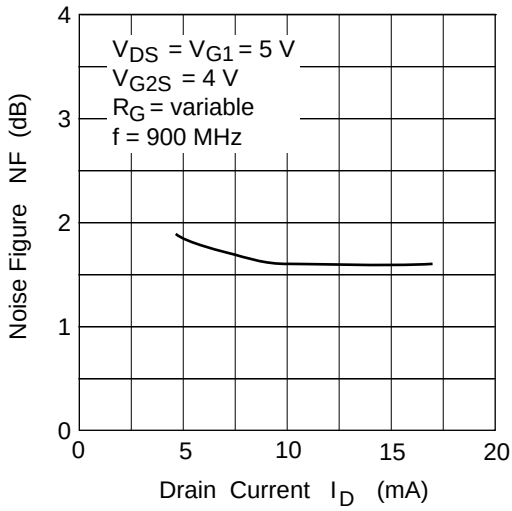
Noise Figure vs. Gate Resistance



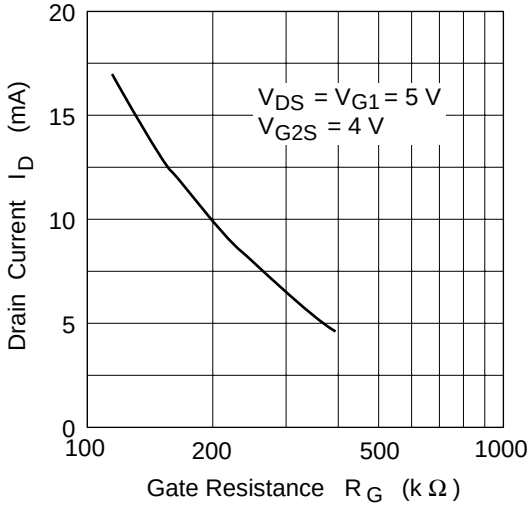
Power Gain vs. Drain Current



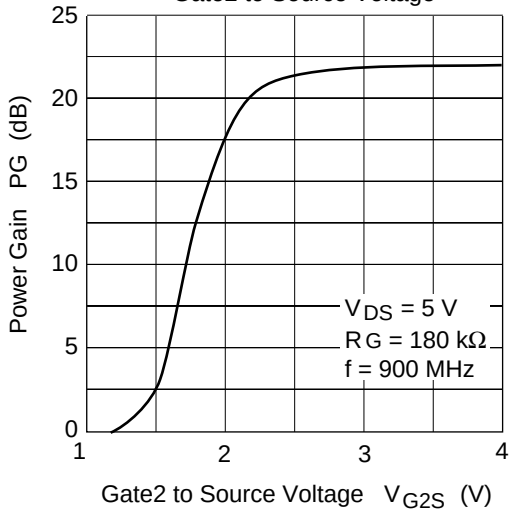
Noise Figure vs. Drain Current



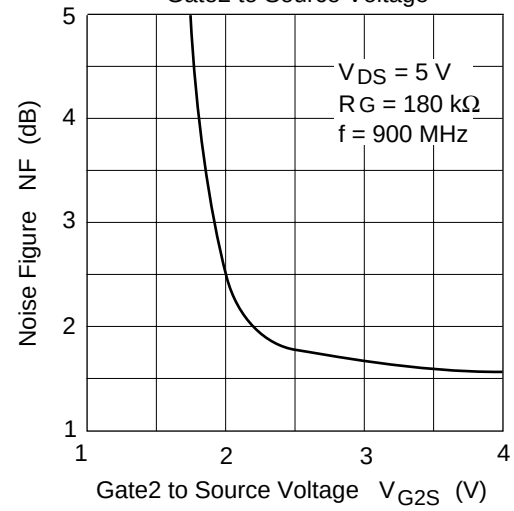
Drain Current vs. Gate Resistance



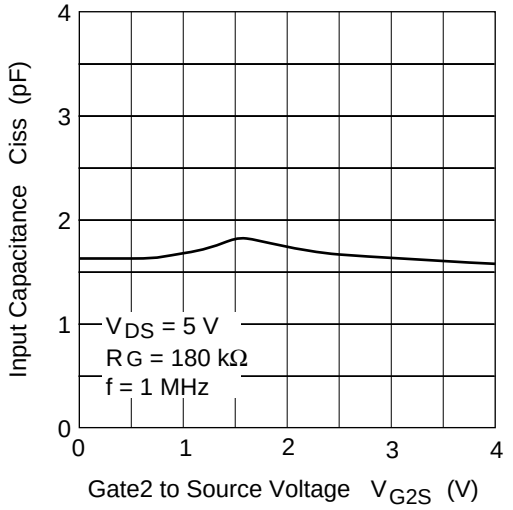
Power Gain vs.
Gate2 to Source Voltage

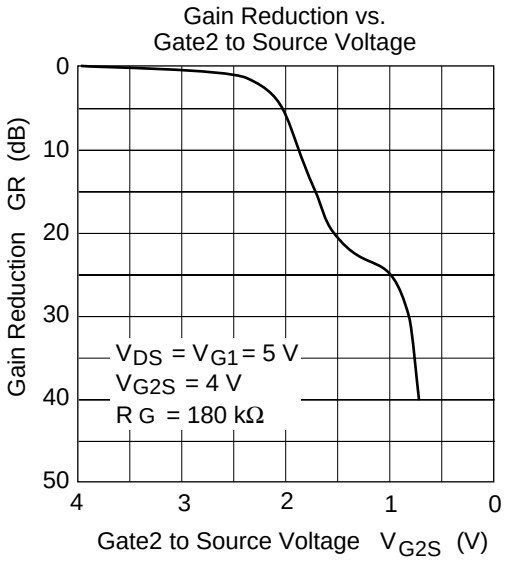


Noise Figure vs.
Gate2 to Source Voltage

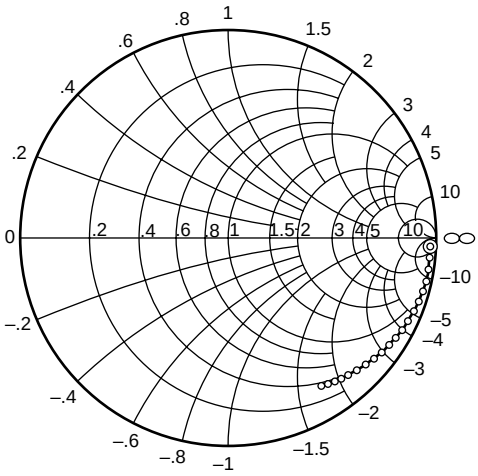


Input Capacitance vs.
Gate2 to Source Voltage




Gain Reduction vs.
Gate2 to Source Voltage
Gain Reduction GR (dB)
0
10
20
30
40
50
4
3
2
1
0
VDS = VG1 = 5 V
VG2S = 4 V
R G = 180 kΩ
Gate2 to Source Voltage VG2S (V)

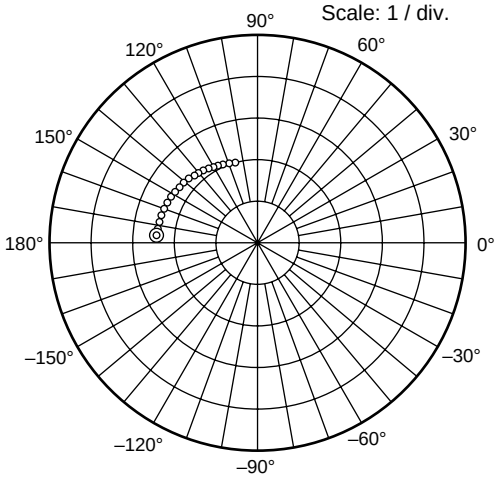
S11 Parameter vs. Frequency



Test Condition: V_{DS} = 5 V , V_{G1} = 5 V
V_{G2S} = 4 V , R_G = 180 kΩ ,
Zo = 50 Ω

50 to 1000 MHz (50 MHz step)

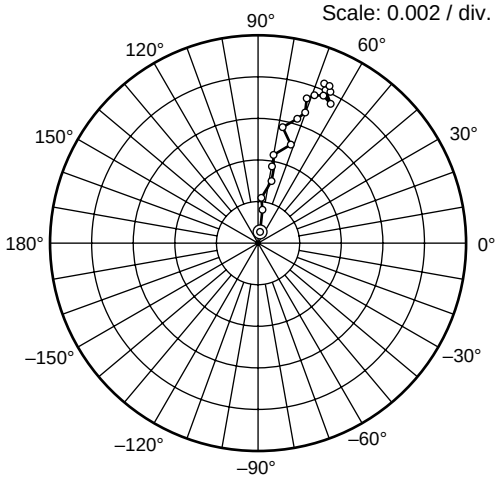
S21 Parameter vs. Frequency



Test Condition: V_{DS} = 5 V , V_{G1} = 5 V
V_{G2S} = 4 V , R_G = 180 kΩ ,
Zo = 50 Ω

50 to 1000 MHz (50 MHz step)

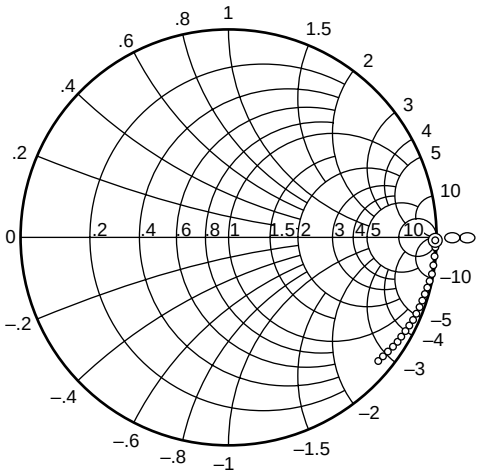
S12 Parameter vs. Frequency



Test Condition: V_{DS} = 5 V , V_{G1} = 5 V
V_{G2S} = 4 V , R_G = 180 kΩ ,
Zo = 50 Ω

50 to 1000 MHz (50 MHz step)

S22 Parameter vs. Frequency



Test Condition: V_{DS} = 5 V , V_{G1} = 5 V
V_{G2S} = 4 V , R_G = 180 kΩ ,
Zo = 50 Ω

50 to 1000 MHz (50 MHz step)

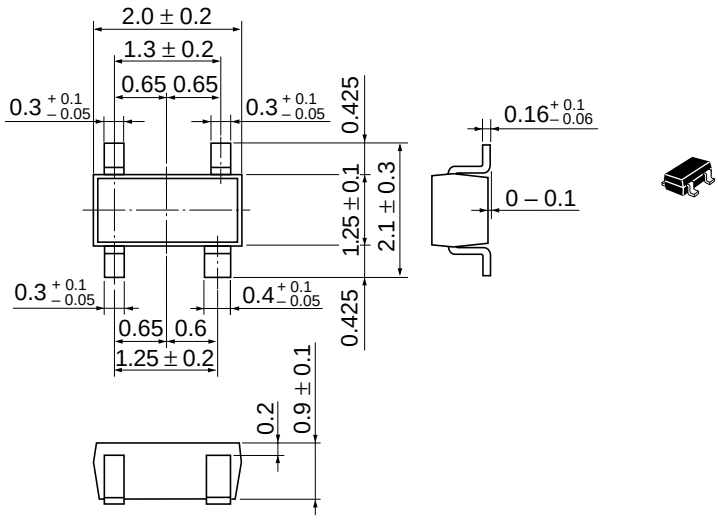
Sparameter (V_{DS} = V_{G1} = 5V, V_{G2S} = 4V, R_G = 180kΩ, Zo = 50Ω)

	S11		S21		S12		S22	
f (MHz)	MAG	ANG	MAG	ANG	MAG	ANG	MAG	ANG
50	0.994	–2.8	2.52	176.2	0.00072	88.6	0.995	–2.2
100	0.994	–5.7	2.51	172.4	0.00161	80.9	0.998	–4.0
150	0.991	–9.2	2.50	168.1	0.00230	86.6	0.997	–6.2
200	0.985	–12.5	2.47	164.1	0.00297	78.0	0.996	–8.2
250	0.985	–15.5	2.46	160.0	0.00374	78.9	0.994	–10.2
300	0.975	–18.7	2.43	156.4	0.00436	80.6	0.992	–12.2
350	0.969	–22.0	2.40	152.3	0.00507	70.9	0.990	–14.2
400	0.962	–24.9	2.38	148.6	0.00557	77.3	0.989	–16.3
450	0.954	–27.7	2.35	144.6	0.00625	72.4	0.987	–18.5
500	0.945	–30.8	2.31	141.0	0.00663	70.0	0.984	–20.4
550	0.935	–33.8	2.28	136.7	0.00721	70.5	0.981	–22.4
600	0.925	–36.6	2.25	133.4	0.00747	68.4	0.978	–24.3
650	0.918	–39.5	2.21	130.3	0.00761	65.6	0.975	–26.4
700	0.909	–42.5	2.18	126.1	0.00807	65.6	0.972	–28.3
750	0.898	–45.0	2.14	122.9	0.00828	67.6	0.969	–30.2
800	0.887	–47.8	2.09	119.5	0.00801	65.1	0.965	–32.2
850	0.874	–50.6	2.07	116.0	0.00815	63.6	0.961	–34.2
900	0.862	–53.0	2.03	112.7	0.00832	65.1	0.958	–36.1
950	0.855	–55.5	1.99	109.4	0.00738	61.8	0.954	–37.9
1000	0.845	–58.1	1.95	108.1	0.00802	65.8	0.951	–39.8

Package Dimensions

As of January, 2001

Unit: mm



Hitachi Code	CMPAK-4(T)
JEDEC	—
EIAJ	Conforms
Mass (reference value)	0.006 g

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